✓^R²

52-90%

94%

OH



1



3

Sajan Patel

Sulfonium and Sulfoxonium Ylides:



^{40%, 69%} ee

N-H Insertion (Sulfoxonium Ylides)



Sulfur Ylides in Organic Synthesis and Transition Metal Catalysis, Springer, 2017 *J. Chem. Soc., Chem. Commun.*, **1993**, 0, 1434-1435 *Org. Lett.*, **2018**, 20, 2464-2467 *Org. Lett.*, **2017**, 19, 5256-5259

C-H Insertion (Sulfonium and Sulfoxonium Ylides)

- poor relation of N-H Insertion
- dimerization is the key challenge
- sulfur ylides are more nucleophilic than diazos and will attack metal carbenoids more readily



B-oxido Carbenoids:

- superior selectivity for single-homologation than the Büchner-Curtius-Schlotterbeck reaction

Tetrahedron, **1987**, 43 (1), 3-38 *Bull. Chem. Soc. Jpn.*, **1977**, 50 (6), 1592-1595 *J. Org. Chem.*, **1970**, 35 (8)





Alkynyl and Alkenyl lodonium Salts:

Angew. Chem. Int. Ed. Engl., **1992**, 31, 274-285 J. Am. Chem. Soc., **1994**, 116, 93-98 J. Am. Chem. Soc., **1988**, 110, 6566-6568 Org. Lett., **2006**, 8 (17), 3659-3662



67%

Aziridinylimines:

- alternative to tosyl hydrazones
- cleaved thermally, good for base-sensitive substrates





Albert Eschenmoser, ETH Zürich



Albert Padwa, Emory University

Diazo Transfer:

Seyferth-Gilbert Homologation

$$\begin{array}{c} 0 \\ R_1 \\ \hline \\ R_2 \end{array} + \begin{array}{c} H \\ H \\ \hline \\ N_2 \end{array} \begin{array}{c} 0 \\ \hline \\ OMe \end{array} \\ \hline \\ OMe \end{array} \begin{array}{c} KO^tBu \\ \hline \\ THF, -78 \ ^\circ C \end{array} R_1 \\ \hline \\ R_1 \\ \hline \\ R_2 \end{array}$$

Bestman-Ohira Modification

good for base-sensitive substrates, such as enolizable aldehydes





in situ generation of Bestman-Ohira Reagent



Kristensen Modification

- uses bench-stable diazo transfer agent - convenient, scalable



Pd-Catalyzed Cross-Coupling of Diazoacetates



Ar-1 + H_{N_2} CO₂Et H_{N_2} H_{M_2} H_{M_2}

Hydrazones as Acyl Anions



Ar.

Ň2

0-80%

CO₂Et

R = Bz, no reaction R = Ph, 91% (N-arylation)

Synthesis, **2004**, 1, 59-62 *J. Am. Chem. Soc.*, **2006**, 128, 14800-14801 *J. Org. Chem.*, **2014**, 79, 9423-9426 *J. Am. Chem. Soc.*, **2007**, 129, 8708-8709